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Phase diagram of boron-doped diamond revisited by thickness-dependent magneto-transport studies

J.Bousquet^{1,2}, T.Klein^{1,2}, M.Solana^{1,2}, L.Saminadayar^{1,2}, C.Marcenat^{3,4} and E.Bustarret^{1,2}

¹ *Université Grenoble Alpes, Institut NEEL, F-38042 Grenoble, France*

² *CNRS, Institut NEEL, F-38042 Grenoble, France*

³ *Université Grenoble Alpes, INAC-SPSMS, F-38000, France and*

⁴ *CEA, INAC-Phelips, F-38000, France*

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We report on a detailed study of the electronic properties of a series of boron-doped diamond epilayers with dopant concentrations ranging from 1.10^{20} to 3.10^{21} cm^{-3} and thicknesses ($d_{\perp}$) ranging from 2 μm to 8 nm. By using well-defined mesa patterns that minimize the parasitic currents induced by doping inhomogeneities, we have been able to unveil a new phase diagram differing from all previous reports. We show that the onset of superconductivity does actually not coincide with the metal-insulator transition in this system. Moreover a dimensional crossover from 3D to 2D transport properties could be induced by reducing $d_{\perp}$ in both the metallic non-superconducting and superconducting epilayers, without any reduction of T_c with $d_{\perp}$ in the latter.

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The discovery of superconductivity in boron-doped diamond was first reported in 2004 by Ekimov *et al.* [1] in high pressure high temperature polycrystalline samples and was rapidly confirmed in both polycrystalline [2] and (100)-oriented single crystal [3] films grown by Microwave Plasma enhanced Chemical Vapor Deposition (MPCVD). Various experimental works including (i) the softening and broadening of the Brillouin zone center phonon mode at the transition [4], (ii) the existence of an isotopic effect on T_c [5] or (iii) the observation of a fully open superconducting gap (Δ) with $2\Delta(0)/k_B T_c$ being close to the standard BCS weak coupling value [6] then provided strong experimental insights in favor of a standard electron-phonon coupling mechanism. With critical temperatures (T_c) rising up to $\sim 10\text{K}$ [7, 8] despite very small carrier concentrations ($\sim 10^{21}$ cm^{-3}), this discovery revived the interest for "superconducting semiconductors" as promising candidates for possible new - conventional - high temperature superconductors (for a review see [9, 10]).

However several questions remain open. Indeed, early studies [7, 11] suggested that T_c remained surprisingly large down to the metal-insulator transition (MIT) and that this system could hence provide new insights on the - still highly debated - mechanism leading to the insulator-superconductor transition (for a review, see [12]). A sharp peak in the resistivity prior to the superconducting transition has for instance been reported in granular diamond films and interpreted as a signature of a metal - Bosonic insulator - superconductor transition [13]. Moreover, it has been suggested that the critical temperature scaled as $T_c \propto (n_B/n_c^{MIT} - 1)^{1/2}$ [11] in striking contrast with the exponential dependence expected from the standard McMillan expression (n_B being the Boron content and n_c^{MIT} the critical concentration corresponding to the MIT) and that T_c strongly - and anomalously - depended on the thickness of the epilayers [14]. All those measurements, clearly indicating a strong interplay between the

onset of superconductivity and the MIT, pointed out this system as an interesting platform to study the interaction between electronic correlations, disorder and superconductivity in the vicinity of the insulator-superconductor transition.

We present here a detailed study of the electronic properties of boron-doped diamond epilayers in the vicinity of the MIT. Both the influence of the doping content and of the epilayer thickness have been revisited. The main novelty of our work is the use of well defined mesa patterns (see Fig.1) that enabled us to control the current distribution within the sample, and hence to minimize the effects associated to parasitic current paths induced by doping inhomogeneities. We have then been able to unveil the existence of a new metallic non-superconducting state separating the insulating (for $n_B \leq n_c^{MIT} \sim 3 \pm 1.10^{20}$ cm^{-3}) from the superconducting states (for $n_B \geq n_c^S \sim 11 \pm 2.10^{20}$ cm^{-3}). We show that disorder, quantified by the Ioffe-Regel parameter [15] $k_F l$ (where k_F is the Fermi wave vector and l the mean free path) might play a role as the onset of superconductivity is observed for $k_F l \sim 1$, but, in contrast to [14], we did not observe any reduction of T_c with the sample thickness ($d_{\perp}$) down to 8 nm. Moreover, we show that superconductivity is very robust to dimensionality as it can be observed in both 3D ($L_T < d_{\perp}$) and 2D ($L_T > d_{\perp}$) regimes (L_T being the thermal diffusion length).

A series of Boron-doped epilayers was grown by MPCVD on top of hundred nanometer-thick Non-Intentionally Doped (NID) layers deposited on IIa- or Ib-type [100]-oriented diamond substrates [17]. The total pressure in the vertical silica tube reaction chamber was set to 33 or 50 torr in order to stabilize the sample temperature to $\sim 910^\circ\text{C}$ and $\sim 830^\circ\text{C}$ during the growth of NID and doped-layer respectively. After a first exposure of the substrate to a pure hydrogen plasma, methane ($\text{CH}_4/\text{H}_2=1\%$ molar ratio) has been added for the buffer layer deposition. The gas

mixture has been complemented by addition of oxygen $\text{CH}_4/\text{O}_2/\text{H}_2$ (0.75%, 0.25%) to reduce the residual boron incorporation and the surface roughness [18]. Finally, gas mixtures with various concentrations of diborane were used for the B-doped epilayers. The substrate was placed either within or at the vicinity of the plasma ball and the growth parameters corresponding to these two positions are summarized in table 1. The thickness of the epilayers was controlled by varying the growth time and checked by ellipsometric measurements [16]. A total number of 26 samples, with doping level ranging between 1.10^{20} and $3.10^{21} \text{ cm}^{-3}$ were grown with thicknesses ranging from 8 nm to $2 \mu\text{m}$.

Transport measurements have been performed between 300 K and 3 K using a Quantum Design Physical Properties Measurements System and down to 50 mK by adding a homemade adiabatic demagnetization refrigeration stage on the former setup and/or by using a standard dilution fridge. Four contact measurements have been carried out on each epilayer first using only silver pasted top contacts (similar to previous studies [11]) and subsequently using well-controlled mesa patterned Hall-bars (see sketch in the inset of Fig.1) delineated from the surrounding doped layers by using O_2 plasma treatment (with Ti/Pt/Au metallic pads). The temperature dependence of the renormalized conductivity of selected characteristic layers, measured on the mesa patterns, are reported Fig.1.

It is important to note that the Boron concentrations discussed throughout this work have been deduced from Hall effect measurements. Even though anomalously small Hall coefficients have been previously reported [7, 11] (hindering any reliable determination of the doping concentration from these measurements), the hole concentrations deduced from our measurements performed on mesa patterned geometries are fully consistent with those deduced from ellipsometry measurements [16] and with the boron content determined by Secondary Ion Mass Spectroscopy measurements (SIMS, see [11] for details) performed on selected samples. Note that we have also obtained significantly reduced Hall coefficients when measuring the Hall effect with contacts directly deposited on the top of the samples without further mesa patterning, hence clearly stressing out the necessity of a systematic delineation of the current paths in order to obtain relevant results.

Similarly, the non superconducting metallic phase could not be observed when measuring the resistivity of the same films with pasted silver pads without further mesa-patterning (as done in [11]). We then obtained a systematic decrease of the critical temperatures in all samples upon mesa-patterning. Not any superconducting transition could be observed for $n_c^{MIT} \leq n_B \leq n_c^S$, unveiling the existence of a non superconducting metallic state in boron doped diamond. On several films, twelve Hall bars have been patterned all over the surface in order to map the distribution of the electronic properties. For $n_B \gtrsim n_c^S$, this mapping procedure revealed the presence

TABLE I: Total gas flow rate, CH_4/H_2 molar ratio, growth rate (in nm/min) and boron to carbon concentration ratio used during the growth process of the epilayers. The substrate was placed either within the plasma ball (position 1) or at its vicinity (position 2).

position	flow rate sccm	CH_4/H_2 %	Growth rate nm/min	B/C ppm
1	100 to 400	4	~ 32	400 to 2500
2	2000	0.5	~ 5	6000 to 12000

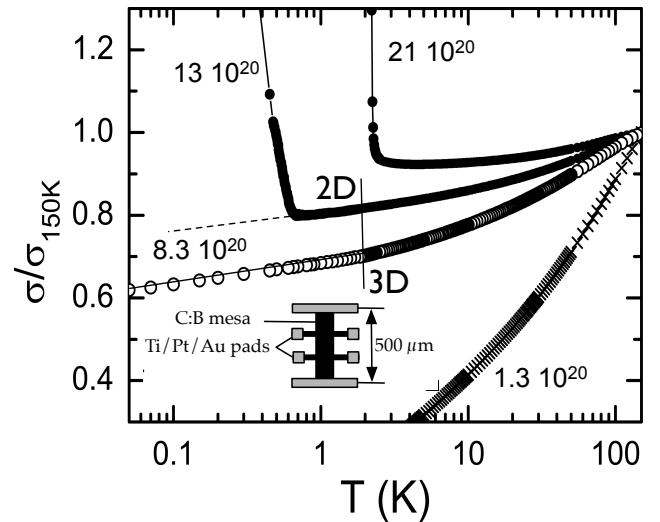


FIG. 1: Temperature dependence of the conductivity (renormalized to its value at 150K) in four boron doped diamond epilayers for the indicated carrier concentration (in cm^{-3}). As shown, both superconducting (solid circles), metallic non superconducting (open circles) and insulating (crosses) samples can be obtained depending on the boron concentration (see text for details). Inset : sketch of the mesa structured Hall-bars patterned on the $3 \times 3 \text{ mm}^2$ epilayers. A dimensional crossover separating 3D and 2D interaction regimes (vertical line) has been observed in the thinnest samples (see Fig.3 and text for details).

of incomplete transitions in some of the Hall bars located close to the sample edges, suggesting the presence of percolation paths with larger boron concentrations within the peripheral area.

After mesa-patterning, a superconducting transition has been observed on about half of the samples (see solid circles in Fig.1) whereas no drop of resistivity could be detected on the second half of the metallic samples down to 50 mK (see open circles in Fig.1). Finally for the lowest Boron concentrations ($n_B < n_c^{MIT} \sim 3 \pm 1. 10^{20} \text{ cm}^{-3}$), an insulating behavior with diverging resistivity at low T is recovered (see crosses in Fig.1). The critical temperatures (defined as the temperature at which the resistivity decreases to 90% of the normal state value)

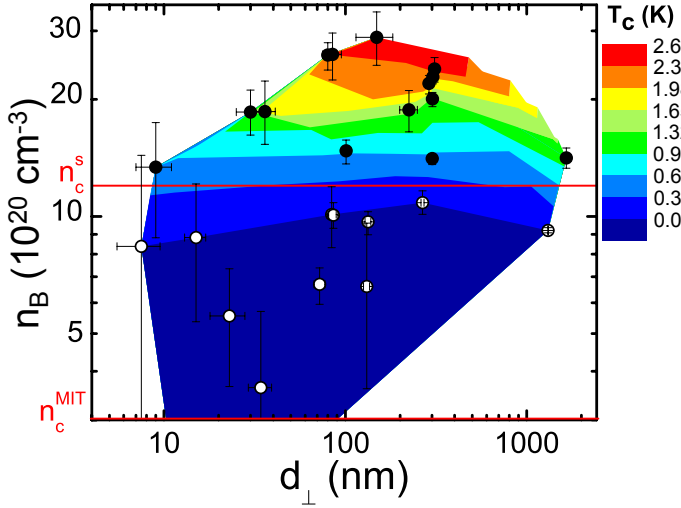


FIG. 2: (color on line) Critical temperature as a function of thickness ($d_{\perp}$) and doping content (n_B , deduced from Hall effect measurements) in C:B epilayers. A non superconducting metallic phase (open symbols) has been observed for $n_c^{MIT} < n_B < n_c^S$ (with $n_c^{MIT} = 3 \pm 1 \cdot 10^{20} \text{ cm}^{-3}$ and $n_c^S = 1.1 \pm 0.2 \cdot 10^{21} \text{ cm}^{-3}$). This color plot clearly indicates that T_c does not depend on the layer thickness (down to 8 nm). Note that 2D like quantum interference effects have been observed in the thinnest samples (see for instance Fig.3c and Fig.3d) showing that superconductivity can be obtained in both 3D and 2D like samples. Insulating layers obtained for $n_B \leq n_c^{MIT}$ have not been reported.

of all layers are displayed in Fig.2 as a function of their thickness and doping concentration. As shown, $T_c \rightarrow 0$ for doping concentrations $n_B \leq n_c^S = 11 \pm 2 \cdot 10^{20} \text{ cm}^{-3}$ revealing the presence of a metallic but non superconducting phase for $n_c^{MIT} \leq n_B \leq n_c^S$. The main result of this work is hence the observation of this metallic non superconducting phase, in striking contrast with previous reports [7, 11] which suggested on the contrary that the onset of superconductivity coincided with the MIT.

Although slightly lower, the n_c^{MIT} value ($\sim 3 \pm 1 \cdot 10^{20} \text{ cm}^{-3}$) obtained in this work is in reasonable agreement with previous reports (see [19] and references therein). This n_c^{MIT} value well agrees with the Mott criterion $k_{FaB} \sim 1$ which assumes that the transition is reached when boron-related hydrogenic states with Bohr radius a_B ($\sim 4 \text{ \AA}$ [20]) overlap (here introducing the Fermi wave vector $k_F^3 = 3\pi^2 n_B$). However, if correlation effects do indeed play a fundamental role, disorder-induced localisation effects also have to be taken into account. Indeed, the Ioffe-Regel parameter $k_{Fl} \sim R_Q/[n_B^{0.33} \rho_{RT}]$ can be determined from the room temperature resistivity $\rho_{RT} \sim m^*/e^2 n_B \tau$ [21] (introducing $R_Q = h/e^2 \sim 25 \text{ k}\Omega$) and, as shown in Fig.4 (top panel), the as-deduced k_{Fl} values are on the order of 1 for $n_B \sim n_c^S$ clearly indicating that both correlation effects and disorder play a significant role in the MIT and possibly in the onset of

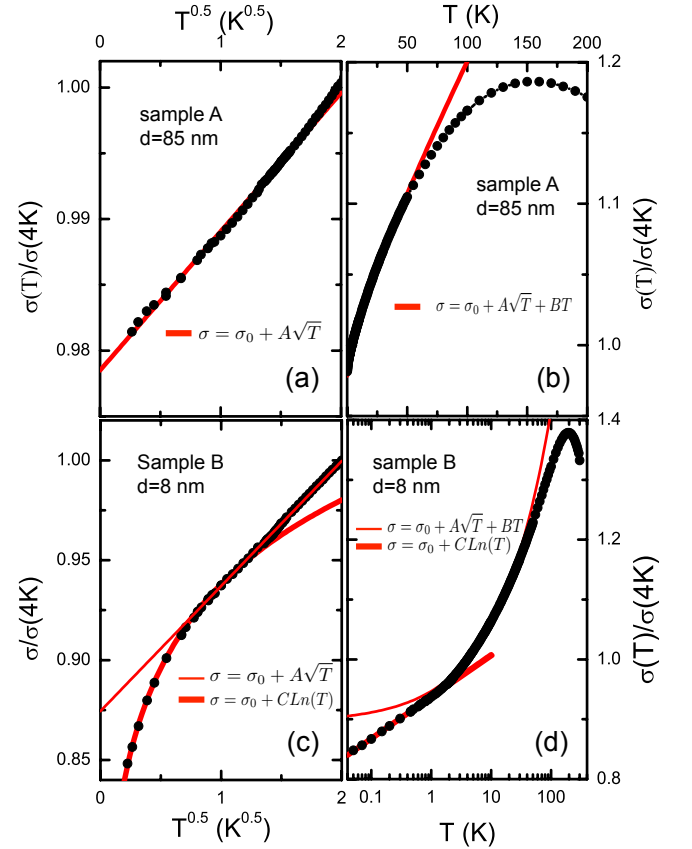


FIG. 3: (color online) Temperature dependence of the conductivity for two C:B samples with $n_B \sim 1 \cdot 10^{21} \text{ cm}^{-3}$ and $d_{\perp} \sim 85 \text{ nm}$ (sample A) and $d_{\perp} \sim 8 \text{ nm}$ (sample B). As shown, for $d_{\perp} \sim 85 \text{ nm}$, $\sigma(T)$ can be well described by a $\sigma_0 + A\sqrt{T}$ law at low temperature (thick solid (red) line in Fig.2a) as expected for 3D electron-electron interaction effects. At higher temperature, weak localisation effect have to be taken into account and $\sigma(T) = \sigma_0 + A\sqrt{T} + BT$ (solid (red) line in Fig.2b, finally a standard metallic behavior is recovered above $\sim 150 \text{ K}$). For $d_{\perp} \sim 8 \text{ nm}$, $\sigma(T)$ is better described by a $\ln T$ term (thick (red) lines in Fig.2c and 2d) than by a $\sqrt{T}$ term (thin (red) lines), as expected in the 2D limit ($L_T > d_{\perp}$).

superconductivity.

As expected, quantum corrections to the Drude resistivity then show up at low temperature and, as previously reported [11, 22], the temperature dependence of all metallic samples can be well described by a $\sigma(T) = \sigma_0 + \sigma_{EEI}(T) + \sigma_{WL}(T)$ [23] law for $T < 50 \text{ K}$ where the electron-electron interaction term σ_{EEI} dominates below $\sim 5 \text{ K}$ (see discussion below) and weak localisation corrections $\sigma_{WL} \sim BT^p$ drive the temperature dependence of the conductivity up to $\sim 50 \text{ K}$. In this temperature range, inelastic scattering is expected to be dominated by electron-phonon interactions and $p = 2$ or 1 depending on the influence of static impurities such as heavy impurities, defects or grain boundaries (see for instance the

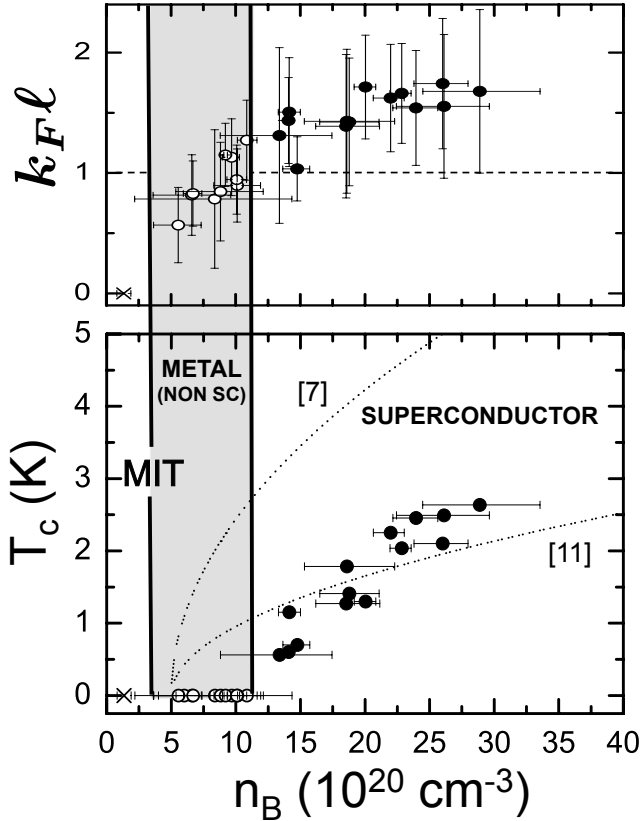


FIG. 4: Critical temperature (lower panel) and $k_F l$ value (upper panel) as a function of boron doping in C:B epilayers. The dotted line (lower panel) represents the doping dependence previously reported in [7] and [11].

discussion in [24]). Very reasonable fits to the data could be obtained taking $p \sim 1-1.5$ (see for instance solid (red) lines in Fig.3b and Fig.3d for $p = 1$ in $d_{\perp} \sim 85$ nm and $d_{\perp} \sim 8$ nm epilayers respectively). We obtained $B \sim 0.5 \pm 0.1 \text{ } \Omega^{-1} \text{ cm}^{-1} \text{ K}^{-1}$ (taking $p = 1$) in all measured samples and the inelastic scattering time τ_{Φ} is hence scaling as $1/\tau_{\Phi} \sim [\pi R_Q B]^2 . DT^2 \sim [2.10^9 \text{ cm}^{-2} \text{ K}^{-2}] . DT^2$ (D being the diffusion constant $\sim 1-10 \text{ cm}^2/\text{s}$). Such a DT^2 scaling of the electron-phonon inelastic scattering rate has been previously reported in disordered systems [25] but a pertinent theoretical model for this dependence is still lacking (see discussion in [25]). Note that a significantly larger τ_{Φ} value has been recently derived from (sub-)THz absorption measurements in the superconducting state of similar epilayers [24] but the origin of this discrepancy has still to be clarified.

Below ~ 5 K, electron-electron interactions clearly dominate and, as expected in 3D samples, the temperature dependence of the thick layers can be well described by a $\sigma(T) = \sigma_0 + A\sqrt{T}$ law down to the lowest temperatures (~ 50 mK, see Fig.3a). However, in the thinnest samples, clear deviations from this law are observed (see Fig.3c for $d_{\perp} \sim 8$ nm) and the temperature dependence is then better described by a $\sigma_{EEI} \propto \ln T$ term for $T \lesssim 2$

K (see Fig.3c), as expected in 2D materials. Indeed, the thermal coherence length $L_T(T) \sim 1/[\pi R_Q A \sqrt{T}] \sim 20[\text{nm}]/\sqrt{T}$ ($A \sim 6 \pm 2 \text{ } \Omega^{-1} \text{ cm}^{-1} \text{ K}^{-1/2}$ in all measured samples), and a dimensional crossover is expected to be reached for $L_T(T_{cr}) \sim d_{\perp}$ i.e. for $T = T_{cr} \sim 5$ K in the $d_{\perp} = 8$ nm sample, in very reasonable agreement with the observed behavior.

As shown in Fig.1 (see also Fig.2) superconductivity is observed in both 2D and 3D interaction regimes, clearly showing that superconductivity is robust to this dimensional crossover. Note that we did not observe any significant decrease of the critical temperature with $d_{\perp}$ (see Fig.2), in striking contrast with the clear decrease of T_c reported by Kitagoh *et al.* [14]. We believe that such an apparent decrease can be induced by doping inhomogeneities. Indeed, interaction effects are expected to lead to a reduction of the critical temperature in thin samples [26]. However, for $R_{\square}/[\pi R_Q] \ll 1$, one expects $\Delta T_c/T_{c,0} \approx -R_{\square}/R_c$ where $R_{\square}$ is the square resistance, $R_c = 6R_Q/\gamma^3$, $e^{\gamma} = [\hbar/\tau^*]/[k_B T_{c,0}]$ and $\tau^* = \max\{\tau, \tau(d_{\perp}/l)^2\}$ [27] and, as $d_{\perp} \gg l \sim 4 \text{ \AA}$, $\gamma \rightarrow 1$ ($\tau \sim 10^{-15}$ s) so that no significant reduction of T_c due to interaction effects is expected in our case.

In conclusion, we have revisited the phase diagram of boron doped diamond epilayers. A new diagram has been obtained by using well-defined mesa patterns that minimize the parasitic currents induced by doping inhomogeneities. This new phase diagram is displayed in Fig.4. The presence of a metallic - non superconducting - phase for $n_c^{MIT} \leq n_B \leq n_c^S$, with $n_c^{MIT} = 3 \pm 1.10^{20}$ and $n_c^S = 11 \pm 2.10^{20} \text{ cm}^{-3}$ has been unveiled. As shown, the critical temperature rapidly rises for $n_B \geq n_c^S$ reaching $T_c \sim 2-3$ K for $n_B \sim 2n_c^S$. Ab-initio calculations [29, 30] suggested that the electron-phonon coupling constant is on the order of $\lambda_{e-ph} \sim 0.2-0.25$ in this doping range and the rapid increase of T_c is consistent with the exponential increase expected by the standard McMillan expression assuming however a reduced μ^* value (on the order of 0.04). As superconductivity vanishes for $k_F l \sim 1$ disorder might play a significant role. Indeed, in this regime disorder is expected to hinder the formation of long range phase coherence and localized Cooper pairs could then be preformed in an exotic insulating phase characterized by a small but hard gap (see [28] and discussion therein). However, our study clearly shows that a metallic phase separates the insulating and superconducting states in striking contrast with this model which predicts a direct transition from the superconducting to the insulating states. Finally, the critical temperature was not affected by the epilayer thickness and superconductivity has been observed in both 3D and 2D interaction regimes.

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